



Announcement

Biennial pattern recognition journal awards 2009 and 2010

The Editor-in-Chief of Pattern Recognition is pleased to announce the winners of the 2009 and 2010 awards. These Biennial Awards are made for the best papers published in the journal Pattern Recognition.

Other outstanding papers are also recognized as "Honourable Mention".

Manuscripts published in volumes 42 (year 2009) and 43 (year 2010) have been judged by the Editor-in-Chief and the members of the Editorial and Advisory Boards of the journal based on the following criteria:

- 1) Originality of the contribution,
- 2) presentation and exposition of the manuscript, and
- 3) citations by other researchers.

The winners of the Best Papers are awarded a cash prize and bronze medal shown below:

**Winner of the Best Paper Award for 2009:**

"Description of interest regions with local binary patterns"

M. Heikkilä, M. Pietikainen, C. Schmid

Pattern Recognition Volume 42, Issue 3, March 2009, Pages 425–436.

Honourable Mention:

"Performance of feature-selection methods in the classification of high-dimension data"

J. Hua, W.D. Tembe, E.R. Dougherty

Pattern Recognition Volume 42, Issue 3, March 2009, Pages 409–424.

"A survey of palmprint recognition"

A. Kong, D. Zhang, M. Kamel

Pattern Recognition Volume 42, Issue 7, July 2009, Pages 1408–1418.

Winner of the Best Paper Award for 2010:

"A state of the art in structured light patterns for surface profilometry"

J. Salvi, S. Fernandez, T. Pribanic, X. Llado

Pattern Recognition Volume 43, Issue 8, August 2010, Pages 2666–2680.

Honourable Mention:

"Sparsity preserving projections with applications to face recognition"

L. Qiao, S. Chen, X. Tan

Pattern Recognition Volume 43, Issue 1, January 2010, Pages 331–341.

"Online finger-knuckle-print verification for personal authentication"

Lin Zhang, Lei Zhang, David Zhang, H. Zhu

Pattern Recognition Volume 43, Issue 7, July 2010, Pages 2560–2571.